NOTES:

- 1. SUBSTRATE: UV FUSED SILICA
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec

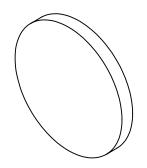
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 560 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 539nm @ 0° AOI
T(abs): =50% FOR 550±5.5nm @ 0° AOI

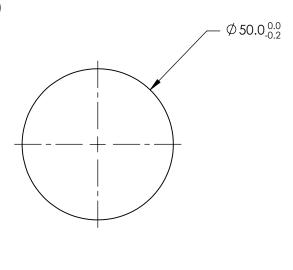
S2:SINGLE LAYER MgF2

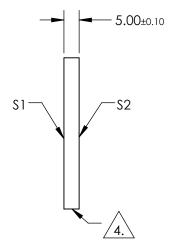
4. FINE GRIND SURFACE

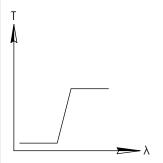
- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm (prior to coating)
- 7. ROHS COMPLIANT











LONGPASS FILTER

	\$1	\$2	
SHAPE	PLANO	PLANO	
SURFACE QUALITY	60-40	60-40	
CLEAR APERTURE	>80%	>80%	
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

Edmund Optics®

THIRD ANGLE PROJECTION		TITLE	Ø50mm, 550nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	84757	SHEET 1 OF 1